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Facile construction of a polydopamine-based hydrophobic surface for protection of metals against corrosion†

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Metal surfaces with a hydrophobic feature, which could prevent percolation of water droplets and improve their resistance against corrosion, have attracted extensive interest. In this work, we demonstrated a method to prepare a hydrophobic copper surface by coating polydopamine (PDA), and modifying with 1-dodecanethiol (1-DT). Surface hydrophobicity was evaluated by contact angle analysis. Attenuated total reflectance Fourier transform infrared spectroscopy (ATR-FTIR), near infrared (NIR) spectroscopy and X-ray photoelectron spectroscopy (XPS) were employed to understand the structure and composition of the resultant coating at the metal surface. The inhibition efficiency of the optimal hydrophobic surface in 3 wt% NaCl aqueous solution, explored by using electrochemical measurements, was 95.3%, which was due to synergy effects of PDA and 1-DT. The promising inhibition of copper corrosion was also validated by scanning electron microscopy observation.

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1 Introduction

Copper is an important metal for marine-related industries due to its mechanical workability, good antifouling, and good electrical and thermal conductivities as well as relatively low corrosion rate.^{1–5} However, the high salt environment of the sea also dramatically speeds up the corrosion of copper, which might result in serious problems with regards to safety.⁶ Benzotriazole andazole derivatives are effective organic inhibitors of copper corrosion in neutral-chloride aqueous solution,^{7,8} yet some of them are toxic, expensive, and not environmentally benign. As a wise alternative, the development of a hydrophobic surface against seawater invasion at the copper surface has attracted increasing attention. Conventionally in the literature, hydrophobic surfaces can be designed using two ideas, namely, rough microstructure and low surface energy. Many methods to construct hydrophobic surfaces, such as spray-deposition,⁹ electro-spinning,¹⁰ and nanocasting,¹¹ have been investigated. Recently, several studies have focused on the on-site formation of hydrophobic films at the copper surface to realize corrosion inhibition.^{12–16} Long hydrocarbon chain alkanethiol

molecules, such as octadecanethiol, and 1-dodecanethiol (1-DT), were also used to self-assemble hydrophobic films at a metal surface, showing an effective inhibition effect.^{17–20} However, they still suffer from instability after long periods of immersion in the harsh sea environment, because the long chain alkanethiol based protection films are normally a monolayer. Therefore, exploring a novel protocol for the construction of robust and hydrophobic layers at a metal surface is also necessary.

Dopamine molecules in aqueous solution in contact with a variety of solid substrates, including metals, oxides, polymers, semiconductors and ceramics, could spontaneously self-polymerize. Under mild conditions, the formation of an adherent polydopamine (PDA) coating on a metallic surface is a simple and rapid process.^{21–24} In addition, in the case of an alkaline environment, dopamine can be easily oxidized to the quinone form by further cross-linking reactions.^{25–27} Unfortunately, cracks are easily found in the PDA coatings, because of their porous membrane-like nanostructures and hydrophilic functional groups.²⁸ Such cracks in the coating will destroy the protective film due to the invasion of corrosive media.

Inspired by PDA coated surfaces, which can be further modified by thiol- or amine-containing molecules for biomaterial applications,^{29,30} in this paper, taking advantage of the preferential adhesion of polydopamine at a surface and modifying it with hydrophobic 1-dodecanethiol, we described a facile approach to design a stable, compact and robust film with superior properties against corrosion in replica sea water of 3 wt% NaCl aqueous solution.

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2 Experimental section

2.1. Materials

Sulfuric acid (analytical grade reagent, AR), hydrochloric acid (AR), sodium chloride (AR), ethanol (AR), 1-dodecanethiol [$\text{HS}(\text{CH}_2)_{11}\text{CH}_3$] (98 wt% purity), and dopamine hydrochloride (98 wt% purity) were purchased from Sigma-Aldrich Corporation. All solutions were prepared with Milli-Q water ($18 \text{ M}\Omega \text{ cm}$).

2.2. Pretreatment of the electrode

The copper rod (99.999 wt%) used in this experiment was inserted into a Teflon sheath with a geometric area of 0.0314 cm^2 . Prior to all experiments, the copper electrode was successively rubbed with 500- and 1000-grits papers to remove scratches, pits and the oxide layer, followed by $0.3 \mu\text{m}$ alumina to polish the electrode until a shiny mirror-like surface was visible. And then the treated electrode was rinsed with Milli-Q water, pure ethanol and again with Milli-Q water to entirely remove the alumina particles and loose copper rust.

2.3. Surface modification

After the above pretreatment, the copper electrode was immersed in Tris-HCl (pH 8.5) buffer with 0.5 mg mL^{-1} dopamine for 2 h and then in 5 mM 1-DT solution for 1 h at room

temperature (25°C). Finally, the copper electrode was rinsed with Milli-Q water and then dried in air.

2.4. Surface characterization

2.4.1. Contact angle test. The surface contact angle was measured by using a commercial device (Powereach®, JC2000D3, China). A $2 \mu\text{L}$ droplet of Milli-Q water was used as the indicator.

2.4.2. X-ray photoelectron spectroscopy test. X-ray photoelectron spectroscopy (XPS, PHI 5000 VersaProbe, Japan) was used to identify the elementary composition at the copper surface.

2.4.3. ATR-FTIR and near infrared spectroscopy (NIR) test. An ATR-FTIR experiment was performed using a Fourier transform infrared spectroscope (Thermo Fisher Nicolet iS5, USA). NIR spectroscopy (Antaris II, Thermo Fisher Scientific, USA) was also used to observe the presence of DT in the PDA film on the metal surface.

2.4.4. Electrochemical experiment. The electrochemical behavior was determined in 3 wt% NaCl aqueous solution by using a CHI750C electrochemical work-station (Shanghai CH Instruments, China) at room temperature. Electrochemical impedance spectroscopy (EIS) results were acquired under an open circuit potential of 0.005 V versus saturated calomel electrode (vs. SCE), an AC amplitude and a frequency ranging from 0.01 Hz to 100 kHz . The electrochemical polarization curves were recorded from -0.4 to -0.05 V (vs. SCE) with a scan rate of 1 mV s^{-1} .

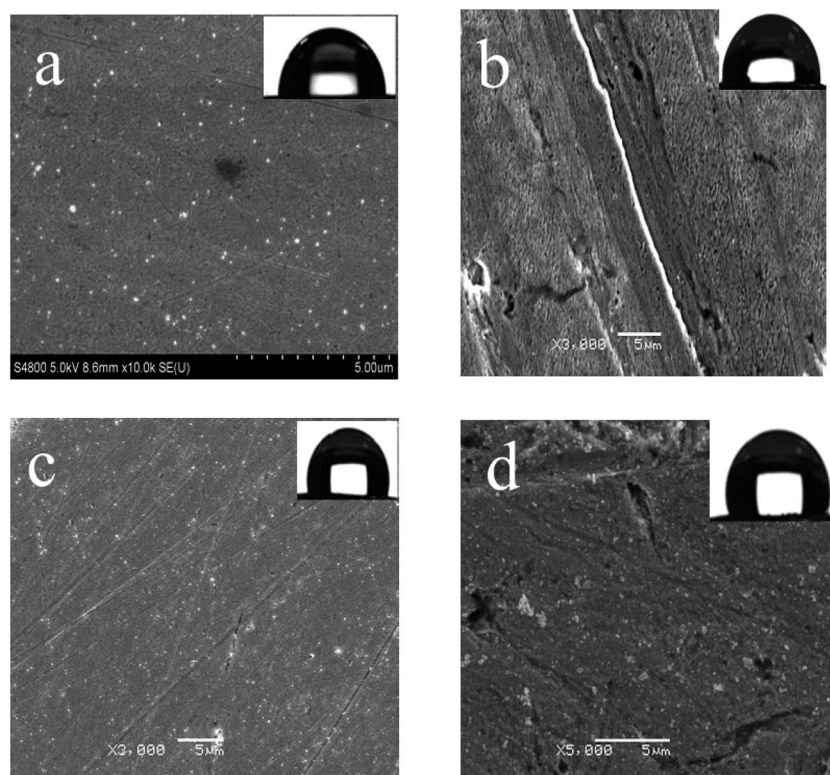


Fig. 1 SEM images of surfaces for (a) bare Cu, (b) PDA@Cu, (c) 1-DT@Cu, and (d) 1-DT@PDA@Cu (the insets are water contact angle images of the copper surfaces).

3 Results and discussion

3.1. Wettability of the copper surface

The wettabilities of bare Cu, PDA modified, 1-DT modified and 1-DT@PDA modified Cu surfaces, which were named PDA@Cu, 1-DT@Cu and 1-DT@PDA@Cu in the following text, were surveyed. As shown in Fig. 1, the contact angle of the bare copper is only 87.2°. After modification with PDA, the contact angle increases to 90.5°. Finally, after modification with PDA and 1-DT successively, the copper surface becomes hydrophobic with a contact angle of approximately 110°.

3.2. Composition of the hydrophobic surface

XPS measurements were conducted to determine the composition at the copper surface. In Fig. 2a, with the scanning bonding energy range from 0 to 1000 eV, the basic elements, including carbon (285.0 eV), oxygen (531.8 eV), and nitrogen (398.4 eV), could be observed, proving the successful modification of the PDA film on the copper surface. In the case of 1-DT@PDA@Cu, the XPS spectral survey also shows C 1s, N 1s and O 1s peaks as the main indication of PDA, while in Fig. 2b, the presence of an S 2p peak at 163.7 eV indicates that 1-DT molecules are successfully grafted on the surface.³¹ Simultaneously, referring to Table 1, the atomic content calculated

Table 1 Atomic content calculated from the XPS survey spectra (Fig. 2)

Sample	Element content (at%)			
	C	N	O	S
PDA@Cu	73.35	7.20	19.45	
1-DT@PDA@Cu	79.75	3.45	14.31	2.49

from XPS spectra shows that the C atom content increases after 1-DT modification. The content of C–C bonds increases from 24.9% to 33.3% in careful comparison with PDA@Cu and 1-DT@PDA@Cu in high resolution XPS results for C 1s, as shown in Fig. 3 and Table 2. For estimating the interaction behaviour of the 1-DT molecules in the resultant film, the corresponding XPS spectrum in the S 2p region was also recorded. In Fig. 4, the peaks centered at 162–163, around 164, and around 168 eV, correspond to thiolates, unbound thiols, and sulfonates, respectively.^{32,33} In this work, the 1-DT molecules are directly anchored to the copper surface *via* thiolates and unbound thiols of the PDA film. It should be mentioned that a sulfonic acid (SO_3^{2-}) group (referring to S (2p_{3/2}) binding energy > 166 eV)³⁴

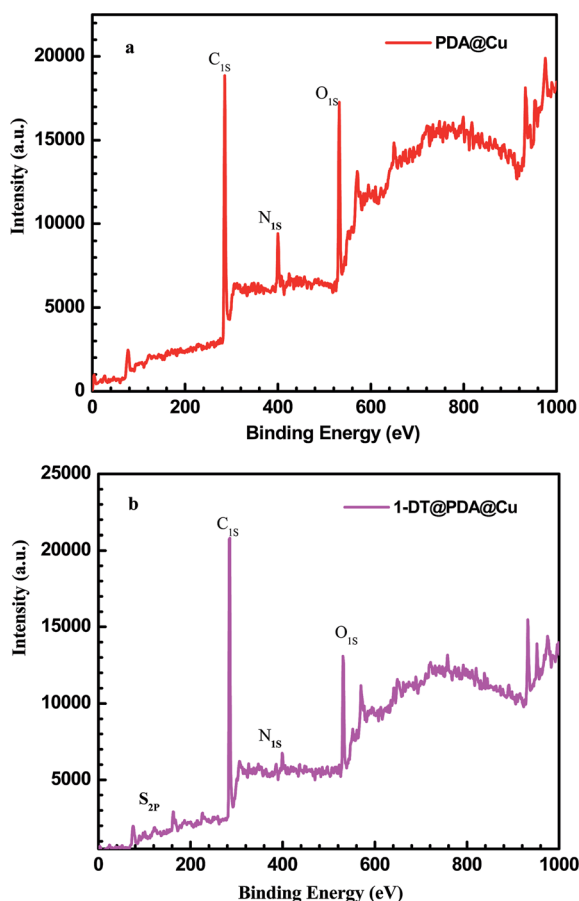


Fig. 2 XPS survey spectra of (a) PDA@Cu and (b) 1-DT@PDA@Cu.

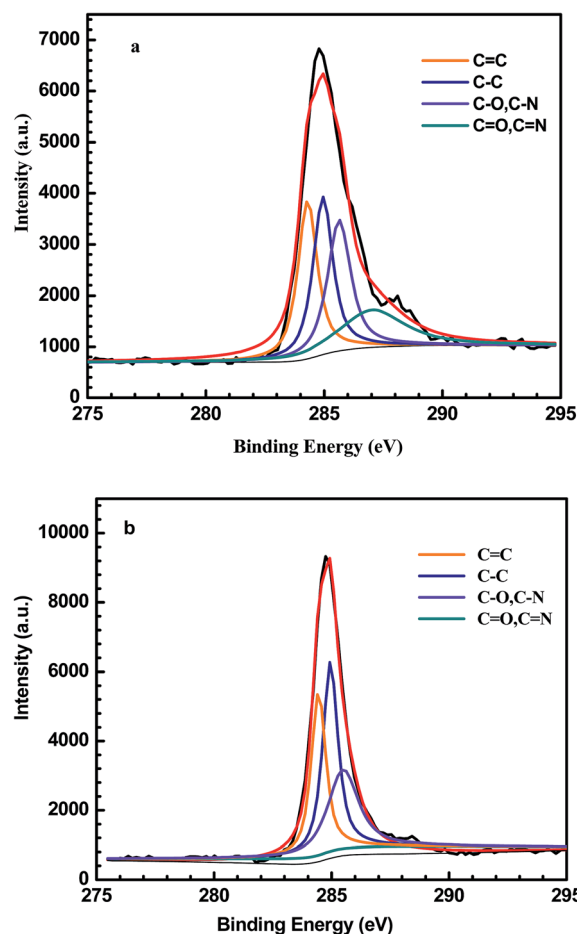


Fig. 3 C 1s XPS spectra of (a) PDA@Cu and (b) 1-DT@PDA@Cu with deconvoluted peaks.



Table 2 Results of high resolution XPS spectra of C 1s shown in Fig. 3

Sample	Bond content (at%)			
	C=C (284.3 eV)	C-C (284.8 eV)	C-O, C-N (285.6 eV)	C=O, C=N (287.4 eV)
PDA@Cu	22.8	28.4	28.4	21.4
1-DT@PDA@Cu	33.3	33.3	33.3	0.01

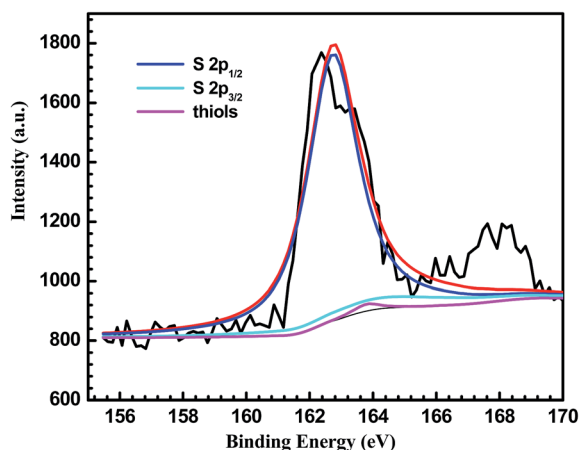


Fig. 4 S 2p XPS spectra of 1-DT@PDA@Cu with deconvoluted peaks.

was also found, which might be the oxidized sulfur species of 1-DT. This consequently suggests that the 1-DT molecules were primarily attached to the copper surface by the formation of Cu-S bonds and side reactions involving hydrogen bonds or physical adsorption.^{35–37}

ATR-FTIR spectra of the modified copper surfaces were acquired to obtain more in-depth interaction information of PDA or/and 1-DT with the copper surface. As shown in Fig. 5, after the modification of PDA, an FTIR band at 1613 cm⁻¹ is ascribed to contributions from phenylic C=C stretching and N-H bending. An IR band centered at 1510 cm⁻¹ is from N-H

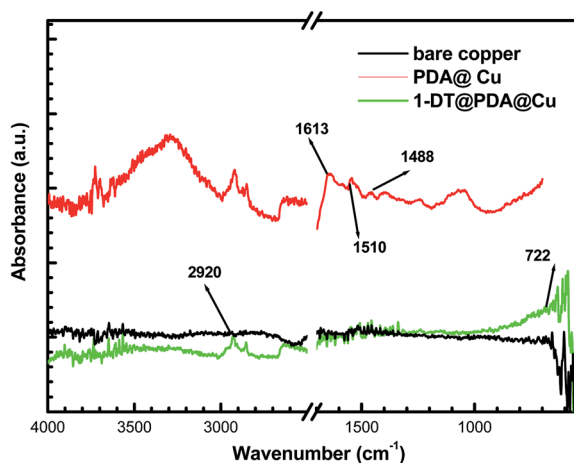


Fig. 5 ATR-FTIR spectra of different copper samples.

scissoring. A peak at 1488 cm⁻¹ is identified as C-N stretching.^{38,39} The relatively broad and strong band in the 3000–3400 cm⁻¹ region should be due to the role of intermolecular hydrogen bonds existing in dopamine molecules.⁴⁰ In the case of the ATR-FTIR spectrum of 1-DT@PDA@Cu, the absence of the S-H stretching band at 2550–2600 cm⁻¹ indicates the chemisorption of 1-DT at the copper surface after cleavage of the S-H bond.⁴¹ Simultaneously, the CH₂ asymmetrical stretching band of 1-DT could be observed at 2920 cm⁻¹, and (CH₂)_n deforming appearing at 722 cm⁻¹ is commonly used as an indicator of long alkyl chains.

NIR is a well-established analytical method for observing abundant overtone bands of hydrogen atom related stretching. To further prove the chemical modifications, we obtained the NIR spectra of pure 1-DT and different DT-modified copper samples. As shown in Fig. 6, for PDA@Cu, no clear peak appears

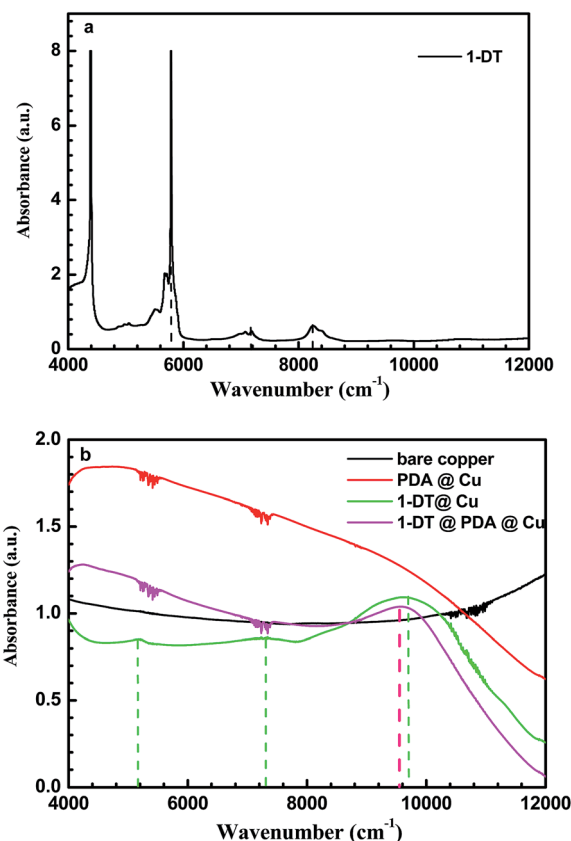


Fig. 6 (a) Near infrared spectrum of 1-DT molecules and (b) near infrared spectra of different copper samples.



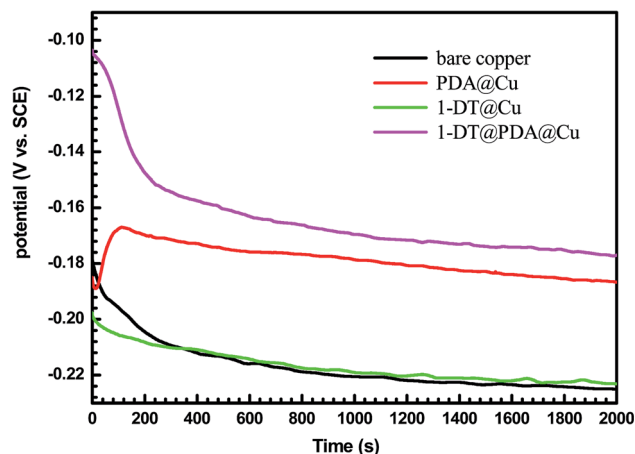


Fig. 7 Open circuit potential versus time of different copper samples recorded in 3 wt% NaCl aqueous solution.

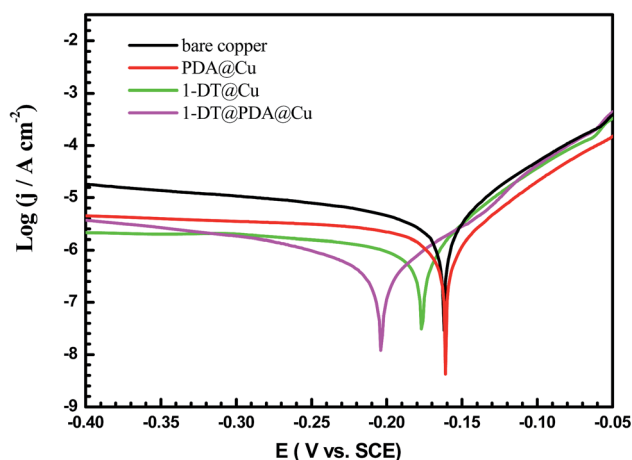


Fig. 8 Anodic and cathodic polarization curves of different copper samples recorded in 3 wt% NaCl aqueous solution.

due to fewer residues of CH groups in polydopamine. In the case of 1-DT@Cu, three different peaks were visible, which should come from overtone stretching of CH long chains in DT. Comparably, NIR absorbance of CH long chains could be clearly seen in the spectrum of 1-DT@PDA@Cu, meaning the 1-DT molecules enter into the cracks of PDA and chemically modify the copper surface. The NIR result agrees with the above XPS investigation that the SH group in the DT molecule could

Table 3 Corrosion parameters obtained from potentiodynamic polarization curves for different samples in 3 wt% NaCl aqueous solution

Sample	E_{corr} (V vs. SCE)	I_{corr} ($\mu\text{A cm}^{-2}$)	β_c (V dec $^{-1}$)	β_a (V dec $^{-1}$)
Bare	-0.162	4.72	1.51	20.03
PDA@Cu	-0.161	2.19	1.52	17.22
1-DT@Cu	-0.177	1.57	2.19	16.99
1-DT@PDA@Cu	-0.204	0.47	3.96	24.02

approach the copper surface and then remove a H atom for the formation of a Cu-S bond.

3.3. Open circuit potential

Fig. 7 shows the open circuit potentials (OCP vs. Ag/AgCl) of bare copper, PDA modified, 1-DT modified and 1-DT@PDA modified Cu versus time. The stable OCP of copper is -0.223 V vs. Ag/AgCl, while the OCP of 1-DT@PDA@Cu is approximately 0.168 V. The latter is more positive than the former, implying that 1-DT@PDA@Cu can reduce the corrosion in NaCl aqueous

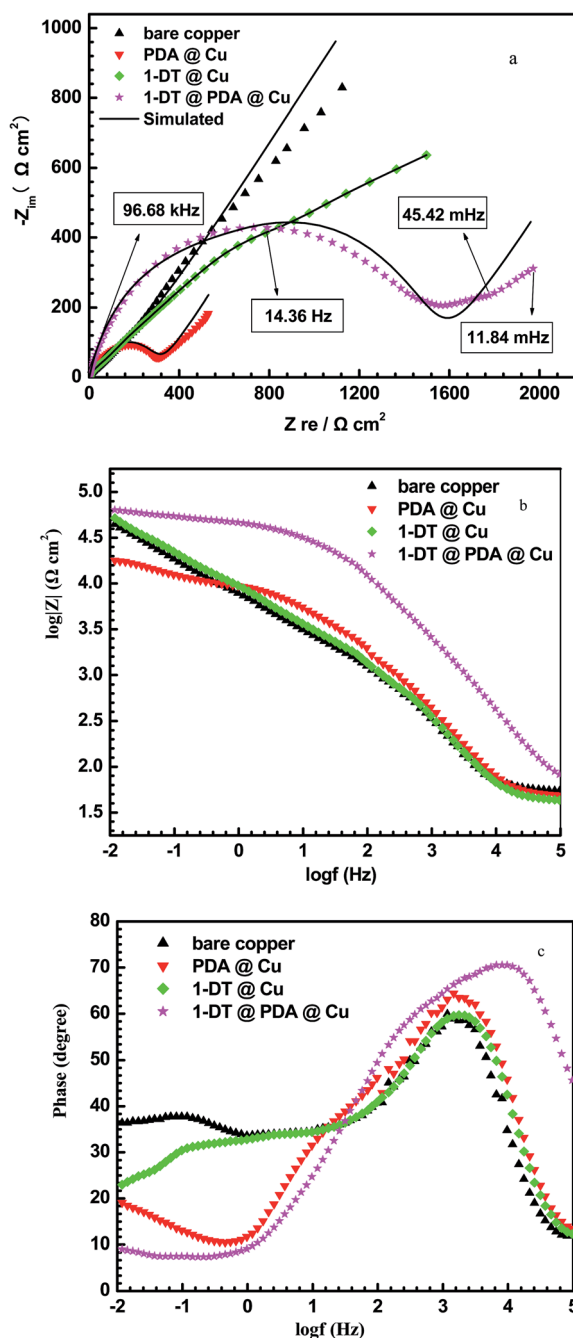


Fig. 9 Nyquist (a), Bode (b) and phase angle (c) plots for different copper samples recorded in 3 wt% NaCl aqueous solution.



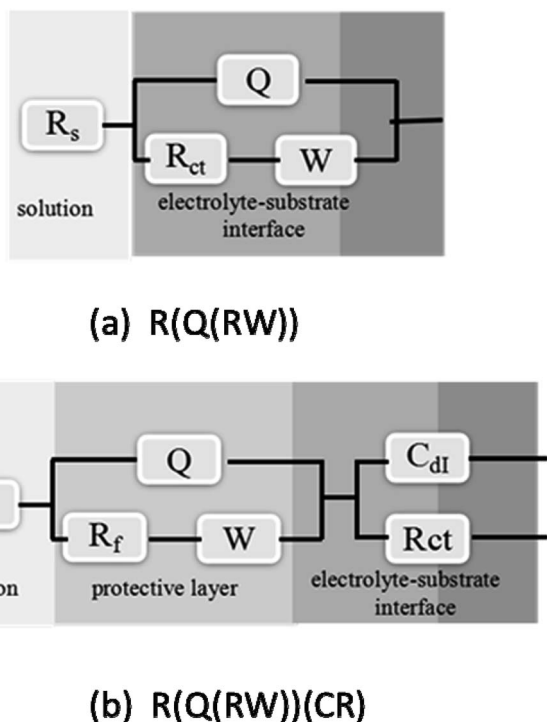


Fig. 10 Electrochemical equivalent circuits simulated for the impedance of the (a) bare copper and (b) modified copper.

solution. The following potentiodynamic polarization and EIS plots for different modified coppers were measured at the corresponding open circuit potentials.

3.4. Electrochemical polarization studies

Fundamentally, metal degradation is an electrochemical corrosion process, which can be estimated by electrochemical methods.⁴² Fig. 8 shows the potentiodynamic polarization curves of the bare Cu, PDA@Cu, 1-DT@Cu and 1-DT@PDA@Cu in 3 wt% NaCl aqueous solution. Extrapolation of the Tafel line allows us to determine the corrosion current density (I_{corr}) together with corrosion potential (E_{corr}), anodic Tafel slopes (β_a), and cathodic Tafel slopes (β_c). These parameters are displayed in Table 3. With respect to the bare copper, all of the modified copper electrodes show lower current densities in both cathodic and anodic directions. Furthermore, the decrease of cathodic current densities for the modified coppers is very noticeable. Therefore, these coatings mainly act as a cathodic type inhibitor on the copper surface. In addition, comparing

with PDA@Cu, the 1-DT@PDA@Cu surface presents a lower I_{corr} value, which is attributed to 1-DT occupying and invading the cracks of the PDA coating. The presence of 1-DT in PDA significantly increases the hydrophobicity of the Cu surface and favors the improvement of the corrosion resistance.

3.5. Electrochemical impedance spectroscopy

EIS measurements help to characterize the interface resistance behavior of the electrolyte/metal with films such as oxides, salts and adsorbed species, when the metal is exposed to the corrosive medium.⁴³ Fig. 9a shows the Nyquist diagrams measured on the copper electrodes with and without a coating. Upon modification of PDA, 1-DT or 1-DT@PDA at the copper surfaces, resistance semicircles could be clearly visible in the high frequency range. Among them, that of copper modified by 1-DT@PDA shows the greatest one. Bode and phase angle plots are also shown in Fig. 9b and c. 1-DT@PDA@Cu shows the maximum phase angle and impedance value. In contrast, the phase angle of PDA@Cu has a similar value to that of the bare copper but a relatively smaller impedance value, further confirming the presence of cracks in the PDA film.

To better understand the mechanism of the corrosion processes, the electrical equivalent circuit (EEC) models were fitted for the EIS data by using ZsimpWin software as demonstrated in Fig. 10. In detail, the model of $R(Q(RW))$ is suitable for the bare copper, while $R(Q(RW))(CR)$ is better for the modified copper surfaces. The merits of fitting can be assessed by standard deviations (χ^2). In all cases, χ^2 is in the range of 10^{-4} to 10^{-3} , an indication of the reasonable simulations. Moreover, another reliable indication of the electrochemical interface in terms of both charge transfer and transport processes within the passive film is that the error for each simulated electrical element in the suggested model should be less than 10%.⁴⁴ In the equivalent circuits of Cu modified with coatings, R_s represents the solution resistance, a time constant involving R_{ct} , and C_{dl} is associated with the charge-transfer process occurring at the copper electrode-solution interface. R_{ct} is the charge-transfer resistance and C_{dl} is the constant phase element (CPE or Q) modeling the capacitance of the double-charge layer. The time constant ($Q_f(R_fW)$) is proposed to consider the diffusion process, including the semi-infinite diffusion induced by corrosive reactants or corrosion products (described by the W element). R_f is the resistance of the inhibitor-adsorption layer and Q_f is the CPE of the layer. The CPE can be described by the following equation:⁴⁵

Table 4 Electrochemical parameters calculated from EIS measurements for different samples in 3 wt% NaCl aqueous solution

Sample	R_s ($\Omega \text{ cm}^2$)	Q_{dl}		R_{ct} ($\Omega \text{ cm}^2$)	W		C_f (F cm^{-2})	R_f ($\Omega \text{ cm}^2$)	η (%)
		$Y_0 \times 10^{-4}$ ($\Omega^{-1} \text{ cm}^{-2} \text{ S}^n$)	n		$Y_0 \times 10^{-3}$ ($\Omega^{-1} \text{ cm}^{-2} \text{ S}^{0.5}$)				
Bare	1.503	0.9867	0.7972	72.29	2.238	—	—	—	—
PDA@Cu	1.372	1.849	0.7764	270.80	11.12	4.442×10^{-5}	32.43	76.2	
1-DT@Cu	1.160	0.5053	0.8943	40.02	3.438	1.555×10^{-3}	452.6	85.3	
1-DT@PDA@Cu	1.043	0.4911	0.7857	1012	5.948	1.336×10^{-5}	524.1	95.3	



$$Z_{\text{CPE}} = Y_0^{-1}(j\omega)^{-n} \quad (1)$$

where Y is the magnitude of CPE, j is the imaginary number, $\omega = 2\pi f$ represents the angular frequency (f is the frequency in Hz) and n is the CPE exponent in relation with the details about the degree of surface inhomogeneity with respect to surface roughness, inhibitor adsorption, porous layer formation, etc. The smaller the n , the rougher the surface morphology of the electrode, due to serious electrode corrosion.⁴⁶ Typically, for $n = 0$, Z_{CPE} is a resistance, when $n = 1$, a capacitance, and for $n = -1$, an inductance. In general, for an electrode in a real scenario, the n value ranges from 0 to 1. 1-DT@PDA@Cu has the largest value of n (0.8943). The fitted electrochemical parameters are tabulated in Table 4. It is obvious that R_{ct} (270.80 $\Omega \text{ cm}^2$) of PDA@Cu is higher than that of the bare copper (72.29 $\Omega \text{ cm}^2$). After modification with 1-DT, R_{ct} of 1-DT@PDA@Cu sharply increases to 1012 $\Omega \text{ cm}^2$, indicating the improvement of inhibition. On the other hand, the increase of the R_f value also indicates the increase of the protection efficiency of the coating. As a result, the largest value of the 1-DT@PDA film resistance (R_f) consequently reveals that 1-DT in the PDA film cracks increases the hydrophobicity.

In addition, the inhibition efficiency of the coatings can be obtained using the following equation:

$$\eta\% = \frac{R_p - R_p^0}{R_p} \times 100\% \quad (2)$$

R_p^0 is the resistance of the bare copper and R_p is the total resistance of the electrode with surface modification. Clearly, neglecting the solution resistance, which is relatively small and almost constant in all cases, the total resistance is the sum of R_{ct} and R_f .^{47,48} As expected, a high inhibition efficiency of 95.3% can be reached for 1-DT@PDA@Cu in NaCl aqueous solution. The EIS observations are in good accordance with the results from the polarization measurements.

It should be said that the inhibition of corrosion of 1-DT@Cu, obtained from OCP results, seems to be different from those obtained from EIS and electrochemical polarization experiments. Hence, we repeated the OCP experiments for PDA@Cu and 1-DT@Cu several times. For PDA@Cu, as shown in Fig. S1 (ESI[†]), the OCP results recorded three times are in quite good agreement, while for 1-DT@Cu, the OCP results are different (see Fig. S2 in ESI[†]). The possible reasons are that the OCP method is a slow dynamic process and the 1-DT monolayer might be undergoing re-organization, which results in various structures of the layers, poor uniformity and density and OCP variation, but the PDA coatings are thick enough to provide stable OCPs. In contrast, EIS and electrochemical polarization are quick processes, which could indicate the behavior of the original 1-DT monolayer at the copper surface.

3.6. SEM observations

Fig. 11 shows SEM images of the bare copper and modified copper substrates, which have been immersed in 3 wt% NaCl aqueous solution for 3 h. Obviously, the localized corrosion

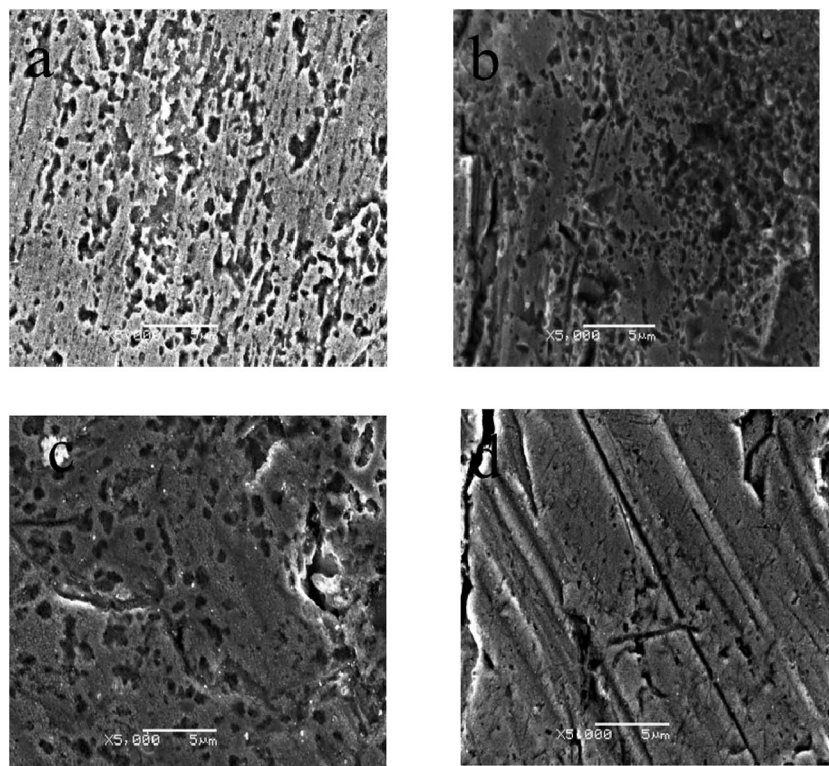


Fig. 11 SEM images of copper surfaces: (a) bare Cu, (b) PDA@Cu, (c) 1-DT@Cu, and (d) 1-DT@PDA@Cu, directly immersed in 3 wt% NaCl aqueous solution for 3 h (corrosion time) at 298 K.



occurred extensively on the bare copper. With the modification with only PDA or 1-DT, the degree of corrosion decreases. Cu with the 1-DT@PDA coating seems smooth and only some tiny inevitable pitting corrosion occurs (compare to the bare copper in Fig. 11a) after immersion in corrosive media. Therefore, hydrophobic 1-DT@PDA layers result in improved protection of the copper surface from salt attack.

4 Conclusions

In summary, by a facile protocol, a 1-DT@PDA coating at the copper surface was fabricated. The resulting film showed high quality hydrophobicity with a contact angle of 110°, whose inhibition efficiency reached 95.3% through an electrochemical method. FTIR, NIR and XPS results elucidated that the greatest protection capability of 1-DT@PDA for copper from corrosion in 3 wt% NaCl aqueous solution should be due to the synergy effect of a uniform PDA coating and 1-DT in the cracks of PDA directly interacting with the copper surface *via* the formation of Cu-S bonds. SEM observation also exhibited the well-protected surface of 1-DT@PDA@Cu.

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